



Form PTO-1449 (modified)	Attorney Docket No. A02P1016US01	Serial No. 10/077,660
LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT(S)' INFORMATION DISCLOSURE STATEMENT	Applicant(s): Euljoon Park; Steve Koh; and Gene A. Bornzin	
(Use several sheets if necessary)	Filing Date: 02/14/2002	Group Art Unit: 3762

U.S. PATENT DOCUMENTS

Examiner Initials	Document No.	Date	Name	Class / Subclass	Filing Date
R.D.	6,480,733 B1	11/12/2002	Turcott	600/516	12/17/1999

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Examiner

R. Bornzin

Date Considered

2/12/04

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Form PTO-949 (modified)	Attorney Docket No. A02P1016US01	Serial No. 10/077,660
LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT(S)' INFORMATION DISCLOSURE STATEMENT	Applicant(s): Euljoon Park; Steve Koh; and Gene A. Bornzin	
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FOREIGN PATENT DOCUMENTS

Examiner Initials	Document No.	Date	Country	Class / Subclass	Translation Yes/No
R.B.	Int'l No.: EP 1 151 718 A2	Int'l Publ. Date: 30.04.2001	Europe	Int'l Classification: A61B 5/0205 A61B 5/0205	RECEIVED SEP 10 2003 TECHNOLOGY CENTER R3700
R.B.	Int'l No.: EP 1 295 623 A1	Int'l Publ. Date: 24.09.2002	Europe	Int'l Classification: A61N 1/37	

Examiner

R. Bornzin

Date Considered

2/12/04

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